

# ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

## Title of Invention

METHOD FOR AVOIDING OXIDE UNDERCUT DURING  
PRE-SILICIDE CLEAN FOR THIN SPACER FETs

Application Number :

Confirmation Number:

First Named Applicant: Atul Ajmera

Attorney Docket Number: FIS920030112US1

Art Unit:

Examiner:

Search string: ( 6391732 or 6255165 or 6461951 or 6133106 or 5643824 or 20020076877 ).pn

## US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
<i>BLS</i>	1	6391732	2002-05-21	Gupta, et al.			
	2	6255165	2001-07-03	Thurgate, et al.			
	3	6461951	2002-10-08	Besser, et al.			
	4	6133106	2000-10-17	Evans, et al.			
	5	5643824	1997-07-01	Chien, et al.			

## US Published Applications

Note: Applicant is not required to submit a paper copy of cited US Published Applications

init	Cite.No.	Pub. No.	Date	Applicant	Kind	Class	Subclass
<i>BLS</i>	1	20020076877	2002-06-20	Gupta, et al.			

## Signature

Examiner Name

Date

*Barak H*

*5/26/05*